

Docket No.: 2328-050

1763#
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Jian CHEN et al

Serial No. 09/821,027

Filed: March 30, 2001

Group Art Unit: 1763

Examiner: Unknown

For: INDUCTIVE PLASMA PROCESSOR HAVING COIL WITH PLURAL WINDINGS AND METHOD OF CONTROLLING PLASMA DENSITY

THE COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D. C. 20231

Dear Sir:

Transmitted herewith is an Preliminary Amendment in the above identified application.

- ☐ No additional fee is required.
☐ Also attached:

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	30	27	3	x \$18 =	\$54
Independent Claims	6	5	1	x \$84 =	\$84
If multiple claims newly presented, add \$260.00					
TOTAL FEE DUE					\$138

- [X] A credit card authorization form for the amount of \$138.00 is attached.
- [X] The Commissioner is hereby authorized to charge payment of any additional fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

LOWE, HAUPTMAN GILMAN & BERNER, LLP



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Date: April 3, 2002

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:

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D. C. 20231

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TC 1/00

Sir:

Prior to examination on the merits, please amend the
referenced application as follows:

IN THE CLAIMS:

Please add claims 28-30 as follows:

a. 28. An inductive plasma processor for processing a
workpiece, comprising a plasma excitation coil, the coil including
at least one winding, a source for supplying power to the at least
one winding, impedance arrangements respectively coupled with the
parallel windings, the source frequency and the length of the at
least one winding being such that there are no substantial standing
wave current variations along the length of the at least one

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